

INFORMATION DISCLOSURE CITATION

(Use several sheets if necessary)

Docket Number (Optional)

01USFP707-R.M.

Application Number

10/026,466

Applicant(s)

Shigeo Nishitoba

Filing Date

December 27, 2001

Group Art Unit

2816

U.S. PATENT DOCUMENTS

EXAMINER INITIAL	REF	DOCUMENT NUMBER	DATE	NAME	CLASS	SUBCLASS	FILING DATE IF APPROPRIATE
		5,672,993	09/30/97	Ronaldue			
		(Duplicate of IDS filed on 1/26/04)					

FOREIGN PATENT DOCUMENTS

	REF	DOCUMENT NUMBER	DATE	COUNTRY	CLASS	SUBCLASS	Translation	
							YES	NO

OTHER DOCUMENTS (Including Author, Title, Date, Pertinent Pages, Etc.)

		Korean Office Action dated October 27, 2003, with partial English translation.
		(Duplicate of IDS filed on 1/26/04)

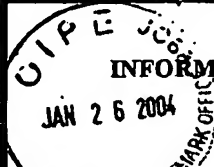
EXAMINER

Long Nguyen

DATE CONSIDERED

2/16/05

EXAMINER: Initial if citation considered, whether or not citation is in conformance with MPEP Section 609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.

<div style="text-align: center;">  <p>INFORMATION DISCLOSURE CITATION (Use several sheets if necessary)</p> </div>	Docket Number (Optional) 01USFP707-R.M.	Application Number 10/026,466
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U.S. PATENT DOCUMENTS

*EXAMINER INITIAL	REF	DOCUMENT NUMBER	DATE	NAME	CLASS	SUBCLASS	FILING DATE IF APPROPRIATE
LN		5,672,993	09/30/97	Runaldue	327	404	

FOREIGN PATENT DOCUMENTS

REF	DOCUMENT NUMBER	DATE	COUNTRY	CLASS	SUBCLASS	Translation	
						YES	NO

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		Korean Office Action dated October 27, 2003, with partial English translation. → Not a publication document.

EXAMINER Long Nguyen	DATE CONSIDERED 2/16/05
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